

ALS-Workshop Oct. 04 on
Magnetic Nanostructures, Interfaces, and New Materials:
Theory, Experiment and Applications

Soft X-Ray Magneto-Optics of Lanthanides

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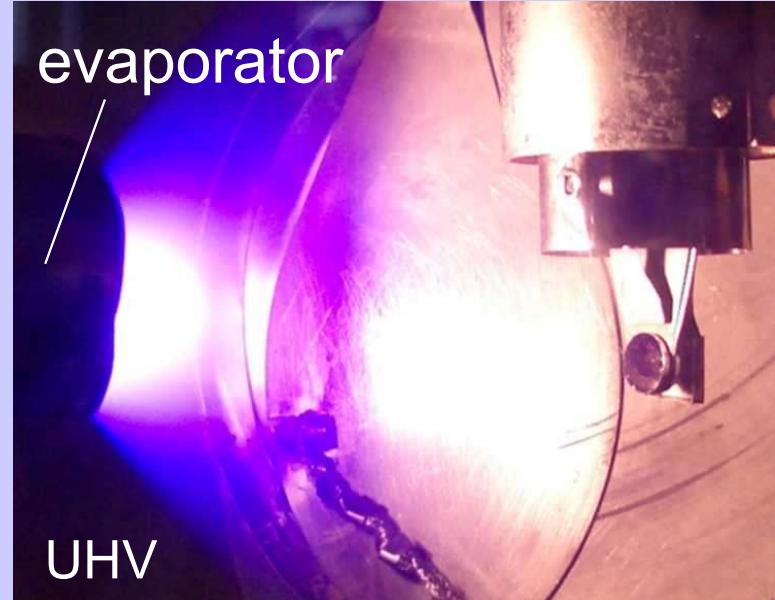
Outline

1. Sample preparation
2. Quantifying MO constants
3. Interlayer coupling (T)

1. Sample preparation

Hetero-epitaxial film growth on crystalline substrates

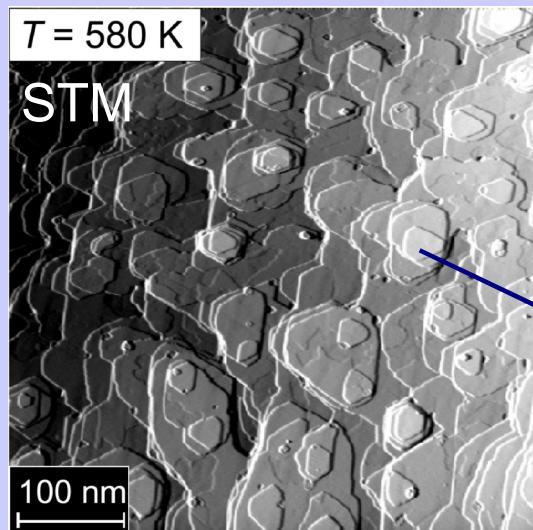
- metal vapor deposition in UHV (10^{-11} mbar)
- :
- growth of “multi”-layers
- cap layers (Al, Ti, ..) for ex-situ studies



Dy plasma during
evaporator cleaning

1. Sample preparation: Tb film on W(110)

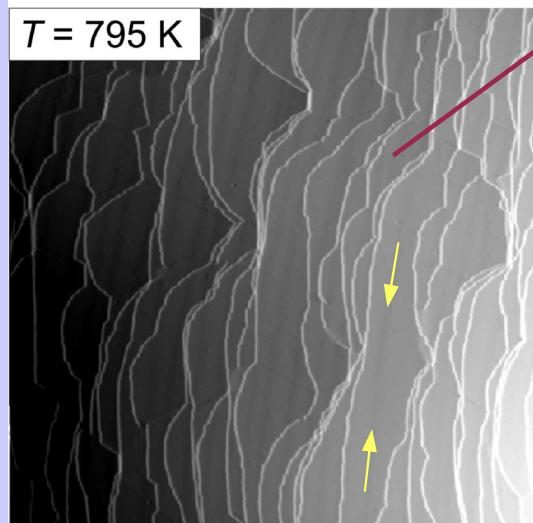
grown at
300 K



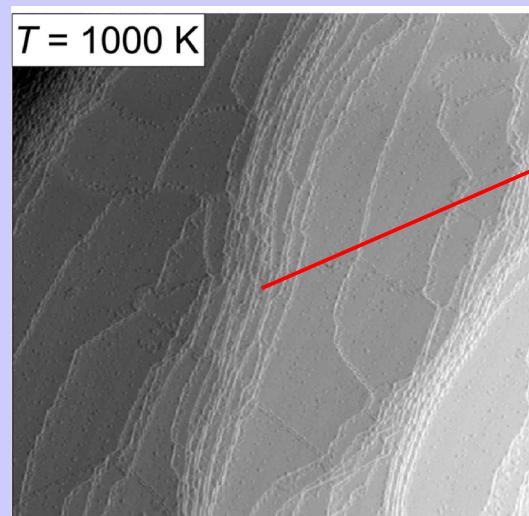
40-layer Tb film morphology changes by annealing

Poisson height distribution
small islands, hcp stacking

annealed
at 795 K



30..50 nm wide terraces
monatomic steps



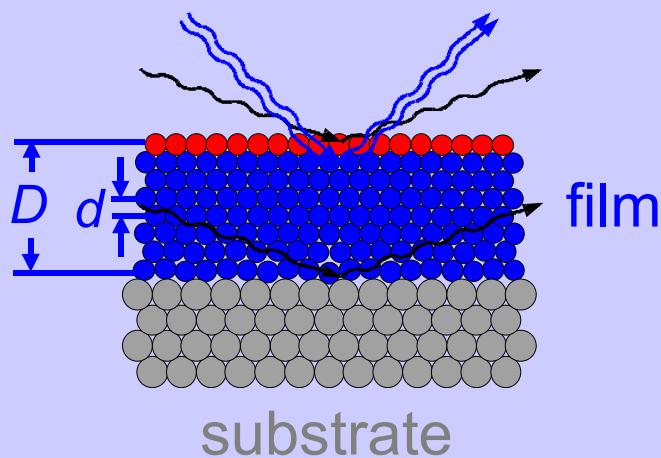
annealed at 1000 K

step bunching

- extended AF phase observed
 $T_N - T_C = 17 \text{ K}$

1. Sample preparation

In situ X-ray diffraction

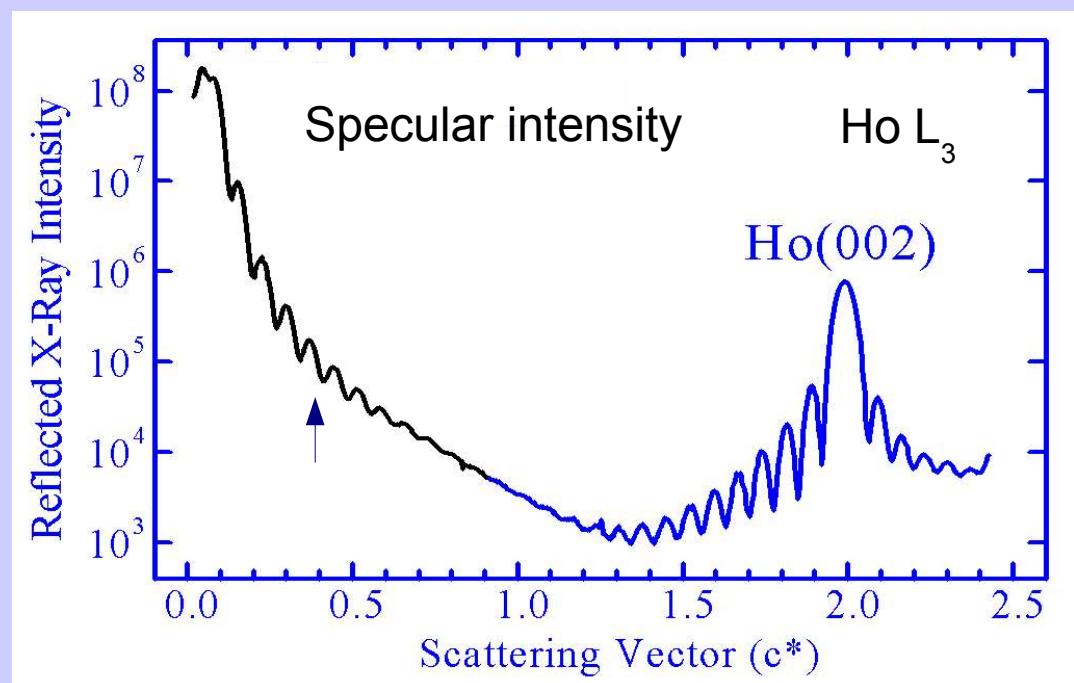


Specular reflection at fixed c^*

- intensity oscillations during growth allows *in situ* characterization

7.7 nm Ho(0001) film on W(110)

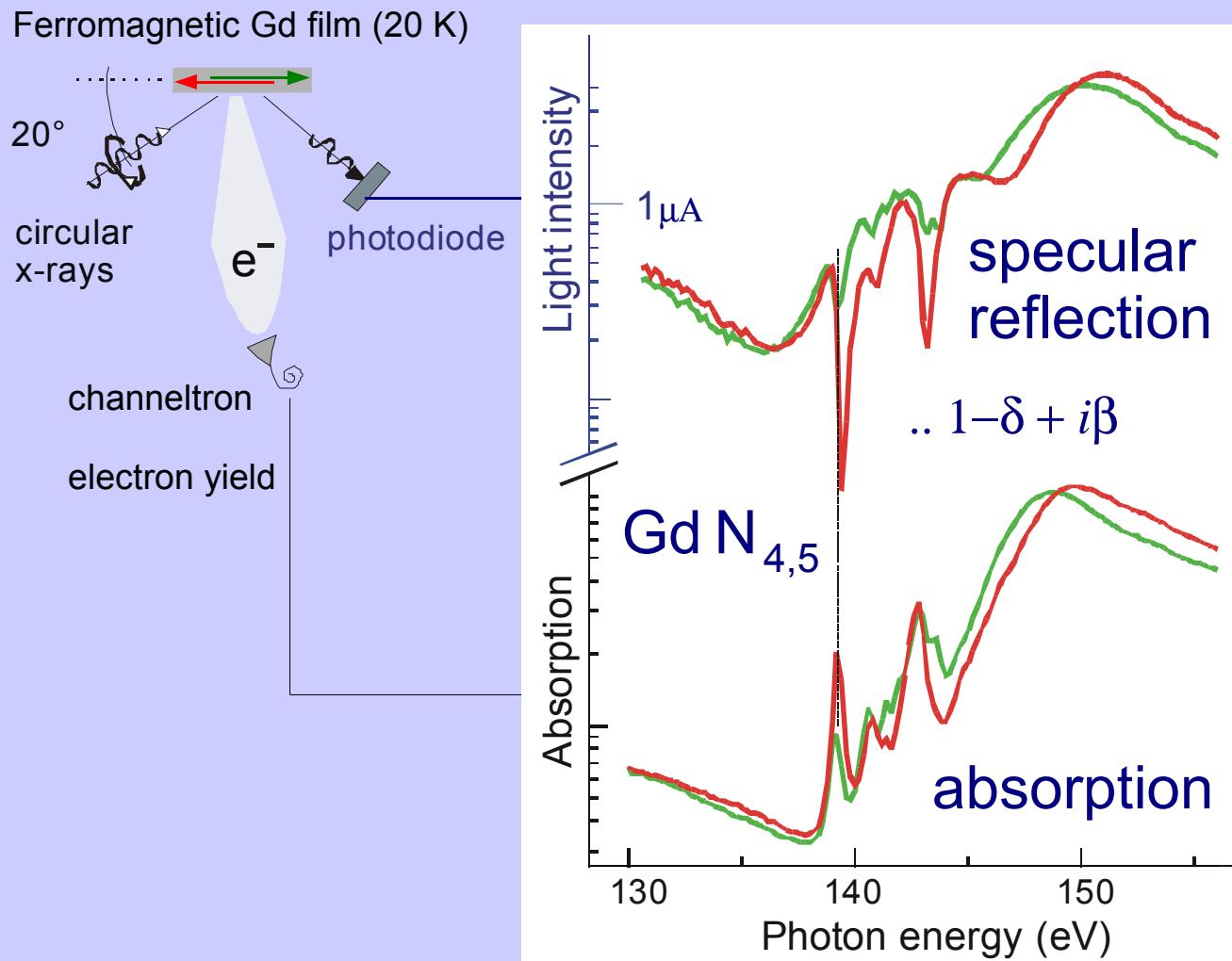
- thickness and roughness
- strain, layer relaxation



E. Weschke, C. Schüssler-Langeheine et al., PRL 79, 3954 (1997)

2. Quantifying MO constants

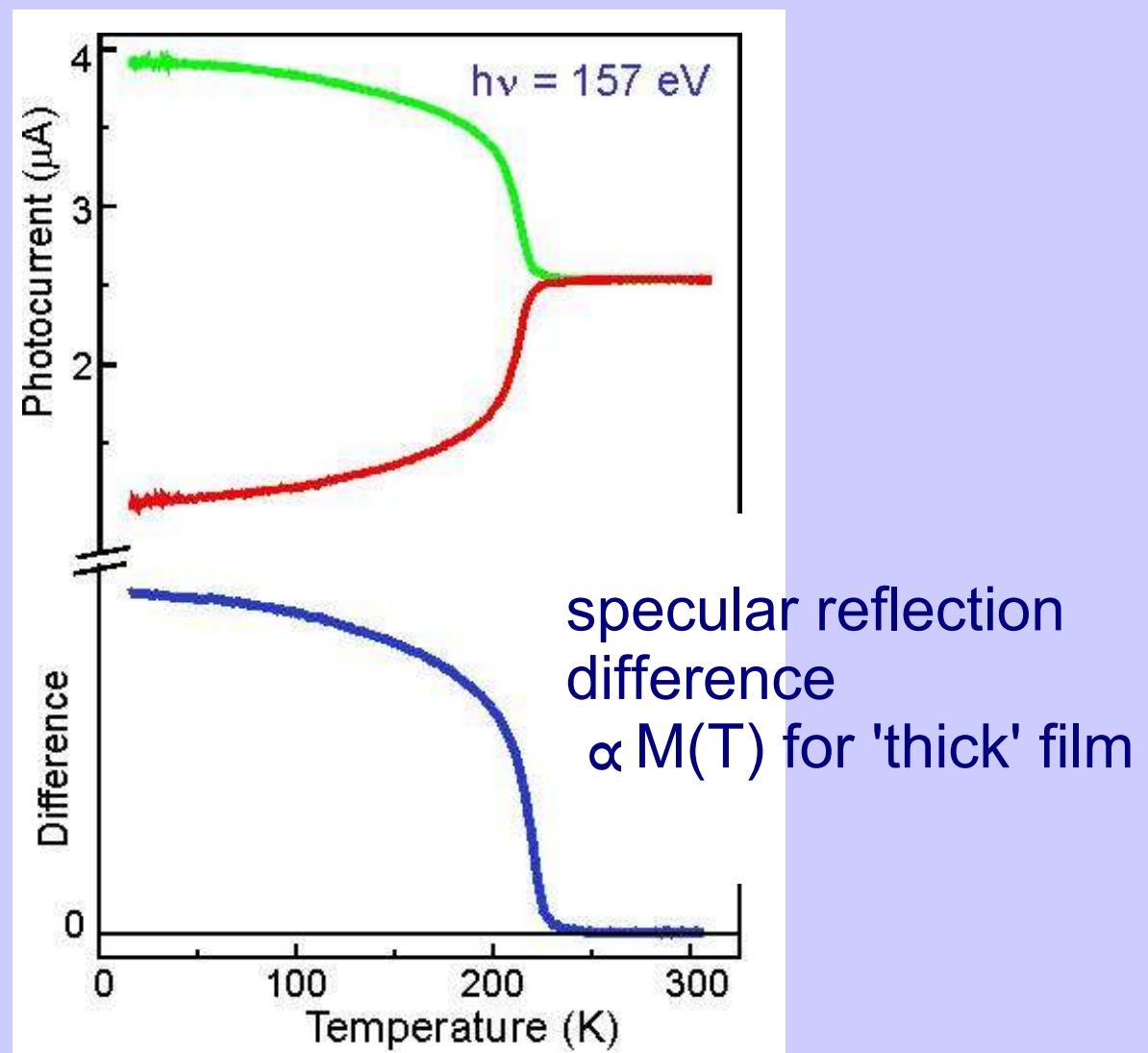
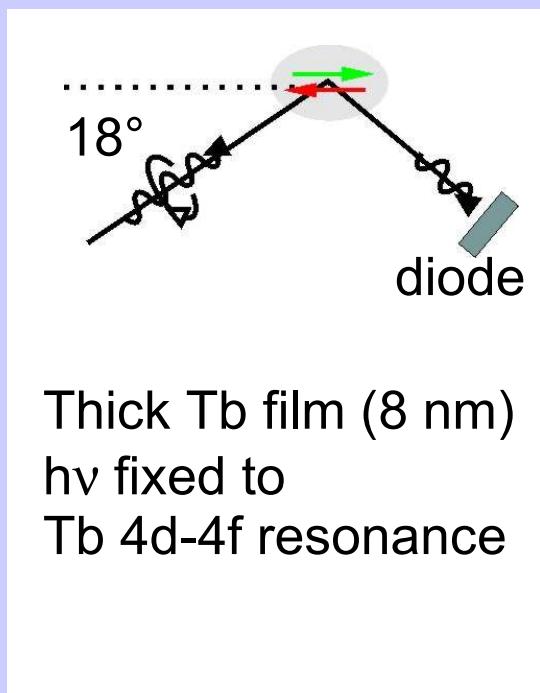
Gd 4d-4f “Giant Resonance” 100..200 eV



- Fano profiles
- 0.01 .. 1 μA specularly reflected photocurrent
- use experimental imaginary part β to calculate n via KKT

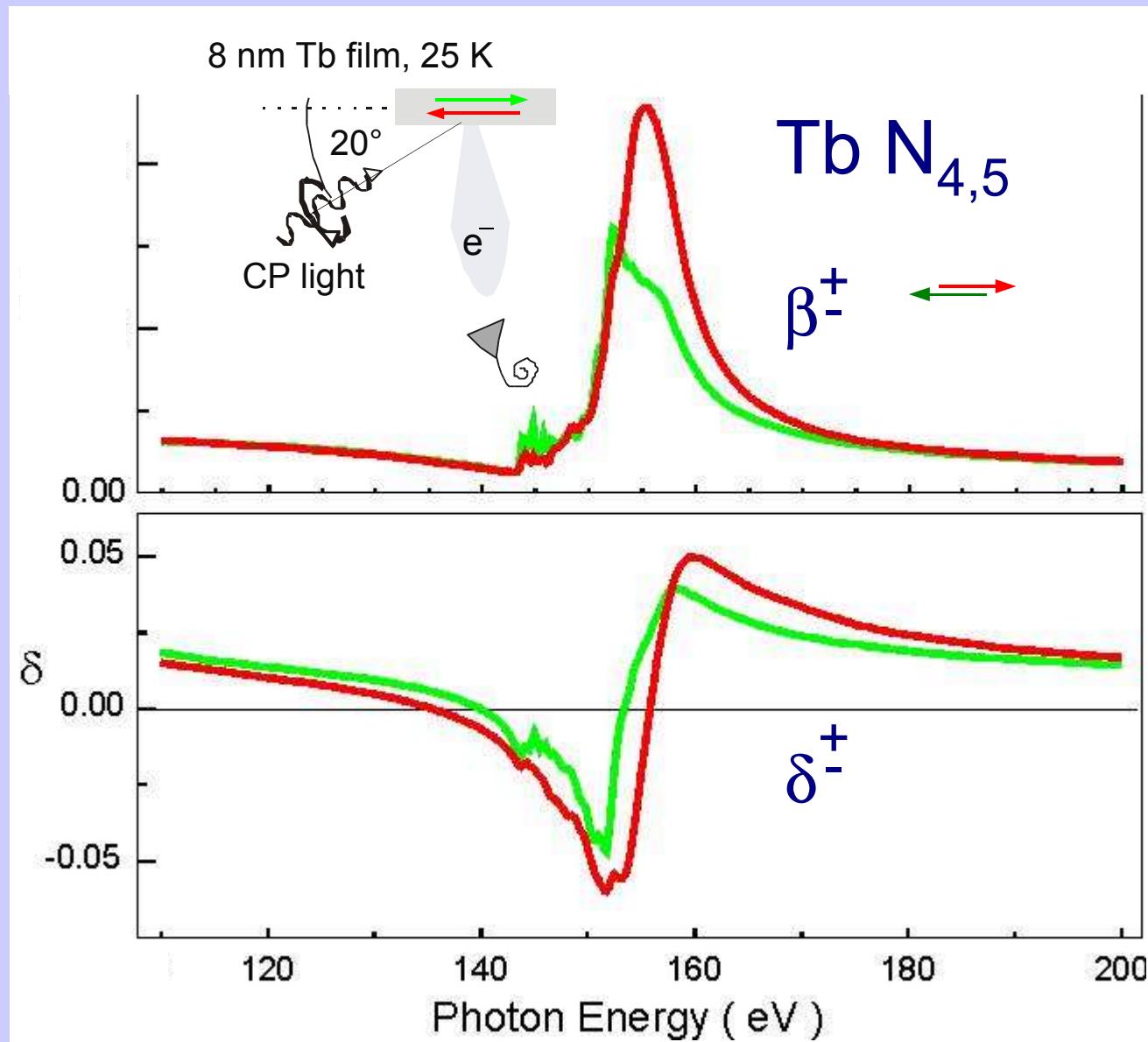
2. Quantifying MO constants

Temperature dependent specular reflection from Tb film



2. Quantifying MO constants

Experimental absorption, dispersion via KKT: Tb N_{4,5}



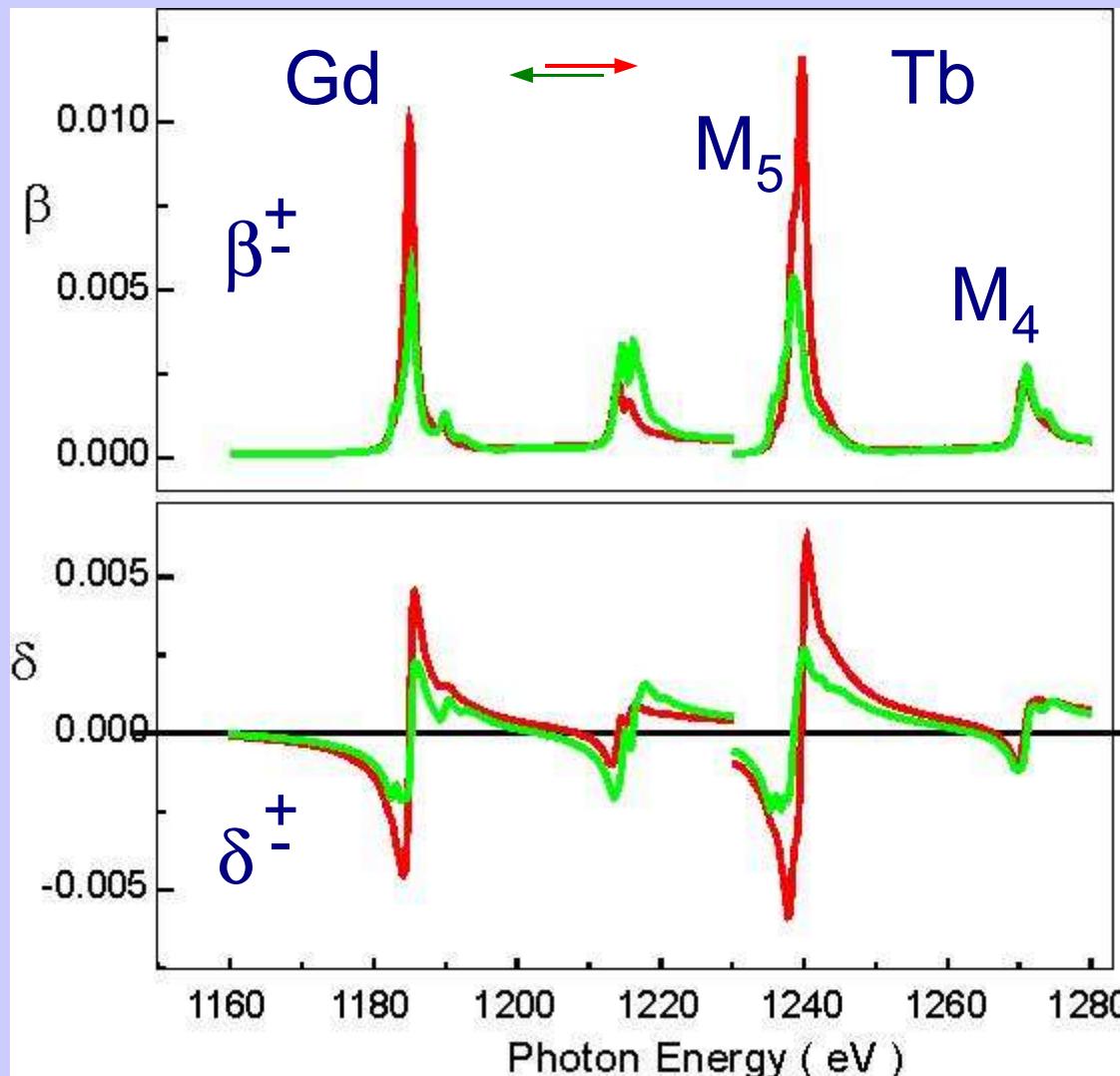
- wide $h\nu$ range to match experimental β to data tables (Henke)

$$n = 1 - \delta + i\beta$$

- δ calculated via KKT using imaginary part β
- option:
 δ and β via KKT from reflectivity spectrum

2. Quantifying MO constants

Determination of MO constants at Gd and Tb $M_{4,5}$

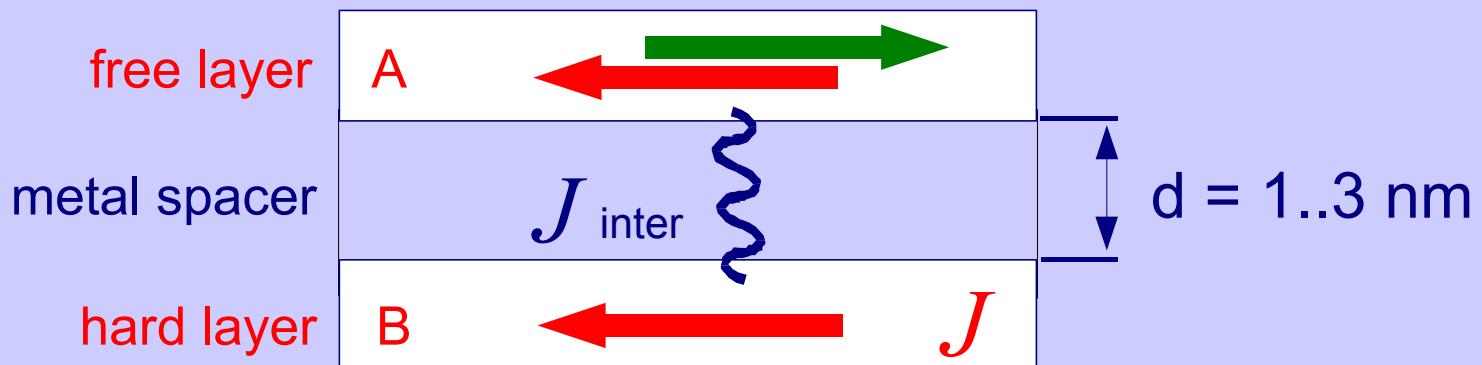


- high element specificity
- apply to exchange coupled magnetic layers

3. Interlayer coupling (T)

mediated by spin dependent QWS

$$2k_{\perp}d + \phi_A + \phi_B = 2\pi n$$



Take rare earth metals for A, B:

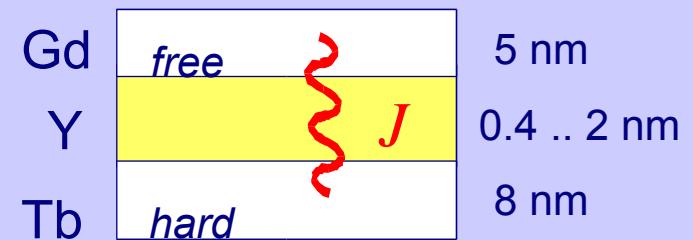
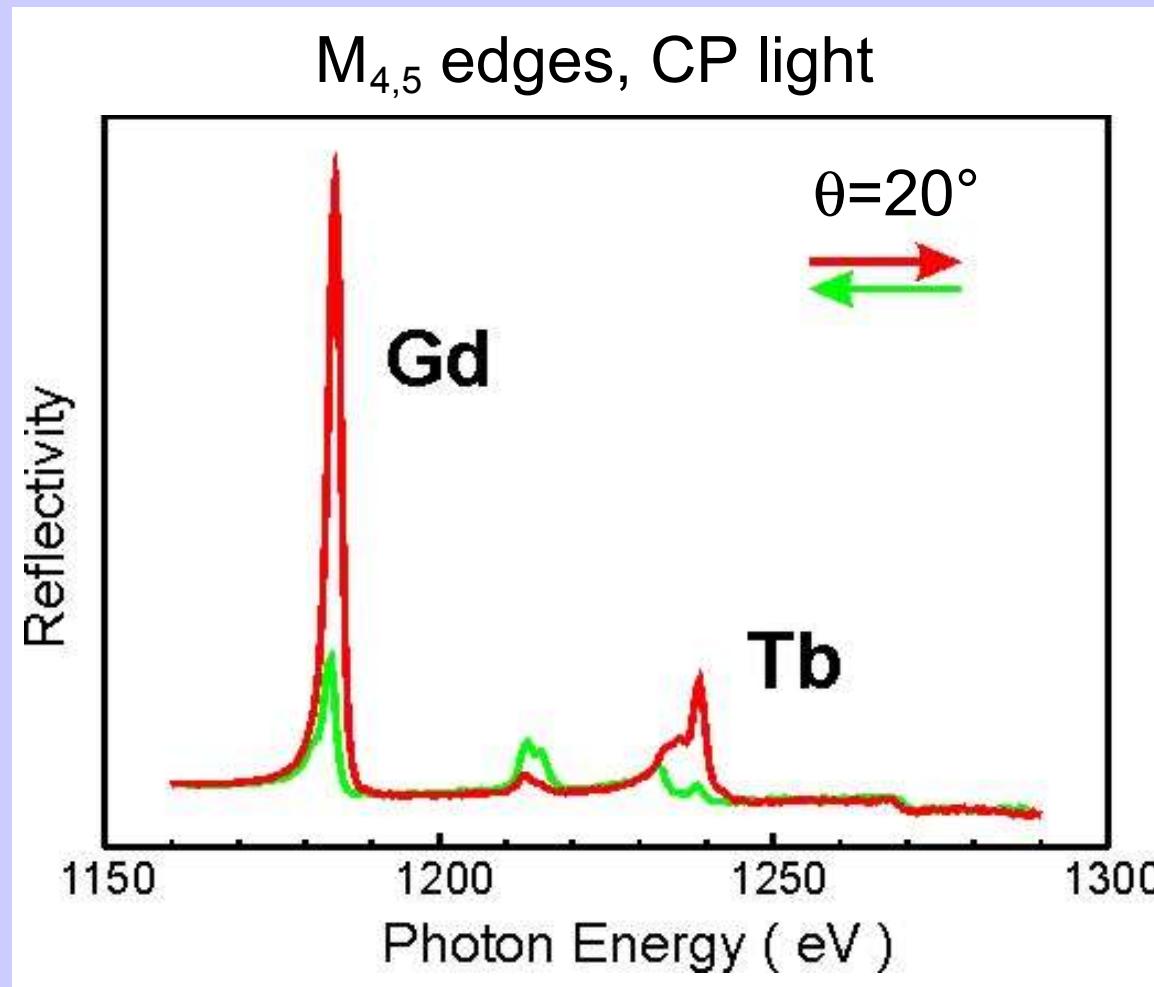
- indirect 4f-5d coupling (RKKY)
- $J \approx J_{\text{inter}}$

Different elements

- individual hysteresis for A, B

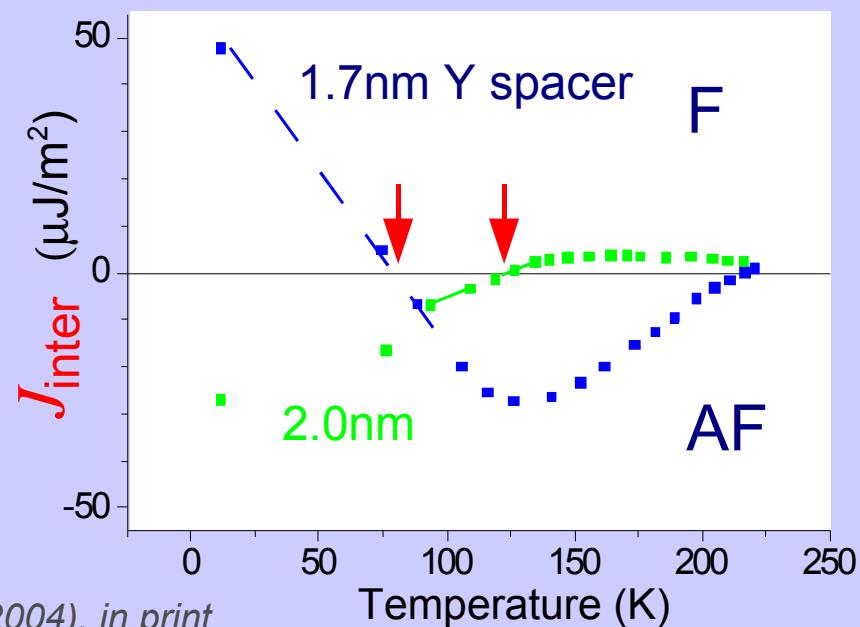
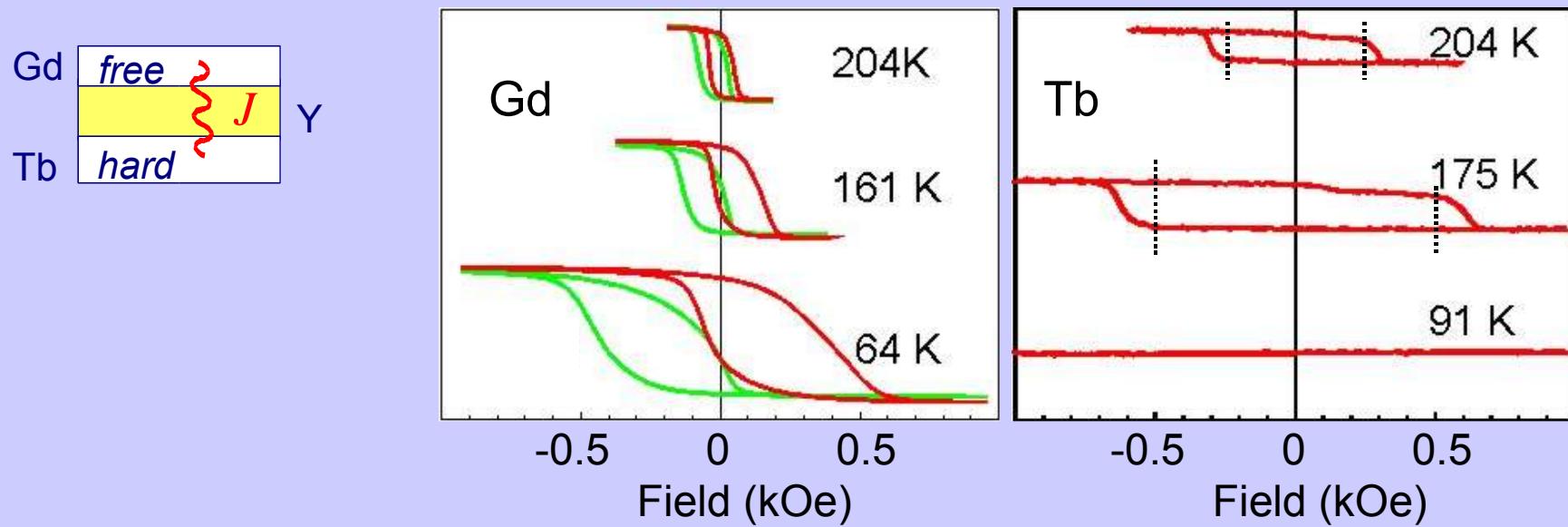
3. Interlayer exchange coupling

Specular reflection at $M_{4,5}$ off a Gd/Y/Tb trilayer



- 0.1 .. 10 nA specular photocurrent

3. Interlayer coupling (T)



crossover from **F** to
AF interlayer
exchange coupling
with temperature

Summary

Sample preparation

Quantifying MO constants

Interlayer coupling (T)

Suggestions for soft x-ray scattering beamline

- Sample preparation (transfer system ?)
- Access to sample
- 500..1500 eV (include very soft?)
- 10..20 K with .. 0.5 T

Collaborations

J. E. Prieto	UA Madrid
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M. Bode	U Hamburg
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J. Feldhaus	DESY
H. A. Dürr	BESSY
A. Scholl	LBNL

..

Students & Coworkers



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